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January 11, 2006

To: Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Fr: George O. Saile, Reg. No. 19,572
28 Davis Avenue
Poughkeepsie, NY 12603

Subject: | Serial No. 10/796,387 03/09/04 |

Cheng T. Horng et al.

A NOVEL PROCESS AND STRUCTURE TO
FABRICATE CPP SPIN VALVE HEADS FOR
ULTRA-HIGH RECORDING DENSITY

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Enclosed is Form PTO-1449, Information Disclosure Citation In An Application.

The following Patents and/or Publications are submitted to comply with the duty
of disclosure under CFR 1.97-1.99 and 37 CFR 1.56.

CERTIFICATE OF MAILING

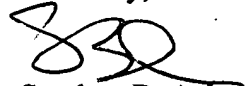
I hereby certify that this correspondence is being deposited with the United States
Postal Service as first class mail in an envelope addressed to: Commissioner for Patents,
P.O. Box 1450, Alexandria, VA 22313-1450, on January 12, 2006.

Stephen B. Ackerman, Reg. # 37761

Signature/Date SB Ackerman 1/12/06

Co-pending U.S. Patent Application HT-03-006, Serial No. 10/661,038, Filed 09/12/03, "Process and Structure to Fabricate Spin Valve Heads for Ultra-High Recording Density Application," assigned to the same assignee as the present invention, discusses the use of an ultra-high vacuum sputtering system to form GMR layers which are inherently furnished with sub-monolayers of adsorbed oxygen (oxygen surfactant layers) for improved deposition properties.

Sincerely,

A handwritten signature in black ink, appearing to read "SBA", with a stylized flourish extending from the end.

Stephen B. Ackerman,
Reg. No. 37761

Reference Number

10/796,387

Cheng T. Horng et al.

03/09/04

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OTPE INFORM
JAN 17 2006
PATENTS TRADEMARK OFFICE

(Be several sheets if necessary)

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FOREIGN PATENT DOCUMENTS

[illegible]

OTHER DOCUMENTS (Including Author, Title, Date, Portion or Pages, Etc.)

-	Co-pending U.S. Patent App. HT-03-006, Serial No. 10/661,038, Filed 09/12/03, "Process and Structure to Fabricate Spin Valve Heads for Ultra-High Recording Density Application",

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.